Journal Name

ARTICLE



SUPPLEMENTARY INFORMATION

Received 16th February 2018, Accepted 00th January 20xx

DOI: 10.1039/x0xx00000x

www.rsc.org/

Temperature dependence of phonon properties in CVD MoS₂ nanostructures – a statistical approach

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In this paper, we report the results of Raman measurements on various molybdenum disulfide (MoS_2) nanostructures grown by the chemical vapor deposition (CVD) method on a typical Si/SiO₂ substrate. The phonon properties investigated include the positions, widths, and intensities of the E_{2g} and A_{1g} modes and the derivative of the mode positions with respect to the temperature in the 300 K – 460 K range. Our results bring new insight into changes in phonon energies in response to different disturbances and show that changes induced by the temperature are similar to the changes induced by stress, making these two factors hardly resolvable in the $\hbar\omega_{A1g}$ – $\hbar\omega_{E2g}$ coordinate system. We prove that all our samples are weakly coupled to the substrate; thus, the presented results almost purely illustrate the effect of the temperature and thickness. The much stronger coupling to the substrate, however, can explain the high variation in the data reported in the literature. The statistical approach applied makes our results highly reliable and allows proper uncertainty assessment of the obtained results, which is helpful when comparing our results to the results reported by other authors.



Fig. S1. Temperature dependence of the E_{2g} and A_{1g} phonon energies (a) for three specified positions on the sample during the first type of morphological transformation or (b) for six specified positions on the sample during the second type of morphological transformation.

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